



IFW  
2814

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

First Named Applicant: Cheng-Ku Chen

Application No.: 09/996,864 (CONF 4851)

Filed: 11/19/2001

Title: Hard mask trimming with thin hard mask layer  
and top protection layer

Attorney Docket No.: 67,200-600

Group Art Unit:  
2814

Examiner:  
Long Pham

Assistant Commissioner for Patents  
Alexandria, VA 22313-1450

Certificate of Mailing

I hereby certify that this paper (along with any referred to as being attached or enclosed) is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to: Commissioner for Patents, Alexandria, VA 22313.

Date:

Oct 7/04

  
Kathy Dixon

RESPONSE TO OFFICE ACTION

Dear Sir:

In response to the Office Action of July 7, 2004, please amend the application as follows, and consider the following remarks.